

Slurry Particle Measurement Carts

High-purity chemical process equipment

- Point-of-use on-line or local bottle sampling capability
- Detect particles 0.5 μ to 20 μ ; other ranges available
- Proven technology widely in use
- Laser accuracy
- Ease of mobility
- OEM standard components
- Optional pH adjustment available
- Teflon[®] PFA wetted components
- Wireless LAN or serial port data output
- Single stage (up to 1,000:1) or dual stage (up to 1,000,000:1) dilution capability
- Mobile, benchtop, or wall-mounted configurations

Large slurry particles can damage wafers. Avoid costly yield reductions resulting from excursions throughout your CMP process. Reduce waste through slurry validation.



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